

3/13/06

U.S. Department of Commerce, Patent and Trademark		Atty. Docket No.		Application No.	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		SNDK.352US0		10/799,060	
(Use several sheets if necessary)		Applicant(s)		Conf. No.	
(Form PTO-1449)		Jeffrey W. LUTZE et al.		6740	
10/2		Filing Date		Art Group	
		March 12, 2004		2818	

U.S. Patent Documents

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
Dle	1	5,554,553	09-1996	Harari			
	2	5,716,863	02-1998	Arai			
	3	5,817,580	10-1998	Violette			
	4	5,966,618	10-1999	Sun et al.			
	5	6,184,093 B1	02-2001	Sung			
	6	6,326,263 B1	12-2001	Hsieh			
	7	6,365,525 B2	04-2002	Miller			
	8	6,391,722 B1	05-2002	Koh			
	9	6,417,051 B1	07-2002	Takebuchi			
	10	6,461,973	10-2002	Hui et al.			
	11	6,465,323 B1	10-2002	Yu et al.			
	12	6,529,410	03-2003	Han et al.			
	13	6,544,431	07-2002	Gill et al.			
	14	6,548,374	04-2003	Chung			
	15	6,562,682	05-2003	Chiü et al.			
	16	6,614,684 B1	09-2003	Shukuri et al.			
	17	6,620,681 B1	09-2003	Kim et al.			
	18	6,768,161 B2	07-2004	Kinoshita			
	19	6,770,932 B2	08-2004	Himeno et al.			
	20	6,794,708 B2	09-2004	Mori			
	21	6,838,357 B2	01-2005	Chen et al.			
	22	6,844,586 B2	01-2005	Ding			
Dle	23	6,894,930	05-2005	Chien et al.			
	24	6,898,121	05-2005	Chien et al.			

Examiner	Dle	Date Considered	6/2006
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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U.S. Published Patent Application Documents							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
Dle	25	2002/0048897 A1	04-2002	Hong			
	26	2002/0072197 A1	06-2002	Kang et al.			
	27	2003/0015497 A1	01-2003	Gill et al.			
	28	2003/0029839 A1	02-2003	Chou			
	29	2004/0126972 A1	07-2004	Dong et al.			
Dh	30	2005/0199939 A1	09-2005	Lutze et al.			

Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
Dle	31	Park et al., "8Gb MLC (Multi-Level Cell) NAND Flash Memory Using 63 nm Process Technology", Samsung Electronics Co., Ltd., Semiconductor R & D Center, pp. 1-4.

Examiner	Dle	Date Considered	6/2006
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U.S. Patent Documents							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
Dle	1	6,172,395	01/2001	Chen et al.			
	2	6,794,708	09/2004	Mori			
	3	6,897,524	05/2005	Kamiya			
	4	6,891,246	05/2005	Aritome			
Dle	5	7,023,049	04/2006	Takebuchi et al.			

U.S. Published Patent Application Documents							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
Dle	6	2002/197800	12/2002	Hashimoto et al.			

Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
Dle	7	EP 1274132 /	01/2003	EPO			<input checked="" type="checkbox"/>	
	8	EP 1363324 -	11/2003	EPO			<input checked="" type="checkbox"/>	

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
Dle	9	"Planarized NVRAM Cell with Self-Aligned BL-BL and WL-BL Isolations", IBM Technical Disclosure Bulletin, IBM Corp. New York, US, Vol. 36, No. 2, 1 February 1993, pp. 375-377.

Examiner	Dle	Date Considered	6/2006
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*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
<i>DL</i>	1	5,343,063	08-1994	Yuan et al.				
	2	6,297,097	10-2001	Jeong, Hee-Cheol				
	3	6,713,834	03-2004	Mori et al.				
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